

Properties of Fe/Si multilayered films with very thin sublayers

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Journal of Magnetism and Magnetic Materials

2001; 226-230(PART II):1790-1791

ARTICLE IDENTIFIERS

DOI: 10.1016/S0304-8853(01)00124-X

PMID: unavailable

PMCID: not available

JOURNAL IDENTIFIERS

LCCN: not available

pISSN: 0304-8853

eISSN: not available

OCLC ID: not available

CONS ID: not available

US National Library of Medicine ID: not available

This article was identified from a query of the SafetyLit database.